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			U.S. PATENT	DOCUMENTS	
Examiner Initials*	Cate No.1	Document Number Number-Kind Code ^{7 Minumb}	Publication Date NM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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Cite No.*	Foreign Patent Document	Publication Date MM-DO-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages Or Relevant Figures Appear	_
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STATEMENT BY APPLICANT			PLICANT	First Named Inventor	Tao Cheng,		
				Art Unit	2836		
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